



AF/10

Docket No.: 449122030700
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Thomas VOGL

Application No.: 09/675,343

Art Unit: 2825

Filed: September 28, 2000

Examiner: A. Liu

For: METHOD FOR RECOGNIZING AND
AVOIDING ETCH-CRITICAL REGIONS

RESPONSE AFTER FINAL ACTION

U.S. Patent and Trademark Office
2011 South Clark Place
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Arlington, VA 222002

Dear Sir:

INTRODUCTORY COMMENTS

In response to the Office Action dated March 31, 2004, Applicant respectfully requests reconsideration and allowance of the claims in light of the following remarks:

Remarks/Arguments begin on page 2 of this paper.